

REVISED VERSION

(19) World Intellectual Property Organization  
International Bureau



(43) International Publication Date  
14 July 2005 (14.07.2005)

PCT

(10) International Publication Number  
**WO 2005/063464 A3**

(51) International Patent Classification:

B29C 59/02 (2006.01) C09J 7/02 (2006.01)  
B29C 35/08 (2006.01) B29D 11/00 (2006.01)  
B32B 31/00 (2006.01)

(21) International Application Number:

PCT/BE2005/000001

(22) International Filing Date: 3 January 2005 (03.01.2005)

(25) Filing Language: English

(26) Publication Language: English

(30) Priority Data:

03079017.4 29 December 2003 (29.12.2003) EP

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(81) Designated States (unless otherwise indicated, for every kind of national protection available): AE, AG, AL, AM,

AT, AU, AZ, BA, BB, BG, BR, BW, BY, BZ, CA, CH, CN, CO, CR, CU, CZ, DE, DK, DM, DZ, EC, EE, EG, ES, FI, GB, GD, GE, GH, GM, HR, HU, ID, IL, IN, IS, JP, KE, KG, KP, KR, KZ, LC, LK, LR, LS, LT, LU, LV, MA, MD, MG, MK, MN, MW, MX, MZ, NA, NI, NO, NZ, OM, PG, PH, PL, PT, RO, RU, SC, SD, SE, SG, SK, SL, SM, SY, TJ, TM, TN, TR, TT, TZ, UA, UG, US, UZ, VC, VN, YU, ZA, ZM, ZW.

(84) Designated States (unless otherwise indicated, for every kind of regional protection available): ARIPO (BW, GH, GM, KE, LS, MW, MZ, NA, SD, SL, SZ, TZ, UG, ZM, ZW), Eurasian (AM, AZ, BY, KG, KZ, MD, RU, TJ, TM), European (AT, BE, BG, CH, CY, CZ, DE, DK, EE, ES, FI, FR, GB, GR, HU, IE, IS, IT, LT, LU, MC, NL, PL, PT, RO, SE, SI, SK, TR), OAPI (BF, BJ, CF, CG, CI, CM, GA, GN, GQ, GW, ML, MR, NE, SN, TD, TG).

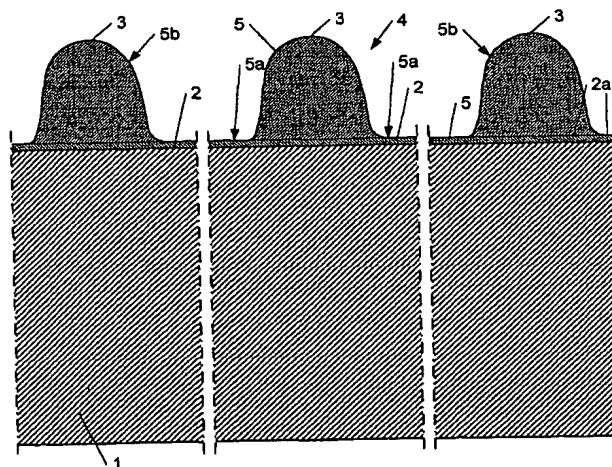
Published:

- with international search report
- before the expiration of the time limit for amending the claims and to be republished in the event of receipt of amendments

(88) Date of publication of the international search report:  
6 October 2005

[Continued on next page]

(54) Title: PROCESS OF MICROSTRUCTURING OF A SURFACE OF A MULTI-LAYERED FLEXIBLE SUBSTRATE, AND MICROSTRUCTURED SUBSTRATE



(57) Abstract: A method of forming a three-dimensional microstructure on a flat surface of a support, comprising the application of a first flat and uniform layer (2) of silicone on said surface of support (1) and the application on the first layer of silicone of a second three dimensionally microstructured layer (3) of silicone, said first layer and second layer of silicone become integrally connected to thus form a common three-dimensional microstructure ensuring anti-adhesive properties distributed regularly on the surface of the support, so that any flexible surface of substrate, in particular a surface of adhesive deposited on said layers of silicone will be microstructured by inverse replication of the three-dimensional microstructure formed by the two layers of silicone, where said layers of silicone are fixed by hardening by heating or by exposure to an ultraviolet or electronic radiation, or a combination thereof, applications thereof and films, notably self-adhesive films, such as those microstructured by said method.



**Date of publication of the revised international search report:** 23 February 2006

**(15) Information about Correction:**

see PCT Gazette No. 08/2006 of 23 February 2006, Section II

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